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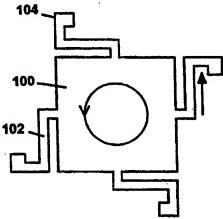
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(74) Agent: FEIGENBAUM, David, L.; Fish & Richards 225 Franklin Street, Boston, MA 02110-2804 (US		2.,
(54) Title: INTERFEROMETRIC MODULATION OF R.	ADIAT	TON
(57) Abstract		

The invention features an interferometric modulator comprising a cavity defined by two walls. At least two arms connect the two walls to permit motion of the walls relative to each other. The two arms are configured and attached to a first one of the walls in a manner that enables mechanical stress in the first wall to be relieved by motion of the first wall essentially within the plane of the first wall.



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Internatic Application No PCT/US 99/07271

A. CLASSIF IPC 6	GOZB26/02		
According to	International Patent Classification (IPC) or to both national classification	and IPC	
B. FIELDS S			
Minimum doc IPC 6	cumentation searched (classification system followed by classification s GO2B B81C G09F		
	ion searched other than minimum documentation to the extent that such		shed
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C. DOCUME	ENTS CONSIDERED TO BE RELEVANT		
Category *	Citation of document, with indication, where appropriate, of the releva	ant passages	Relevant to claim No.
Х	WO 95 30924 A (ETALON INC ;MILES M (US)) 16 November 1995 (1995-11-16	5)	1-8,10, 11,15, 23,24
A	page 33, line 20 -page 34, line 15 28	5; figure	14
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X Fur	rther documents are listed in the continuation of box C.	X Patent family members are listed in	аллех.
*Special of "A" docum cons *E" earliet filing *L" docum while citati *O' docum of the "P" docum later	nent defining the general state of the art which is not sidered to be of particular relevance or document but published on or after the international sides of the state of th	T' later document published after the inter- or priority date and not in conflict with or priority date and not in conflict with cited to understand the principle or the invention X' document of particular relevance; the considered novel or cannot be considered novel or cannot involve an inventive step when the document of particular relevance; the connot be considered to involve an indicator of the cannot be considered to involve an indicator of the combined with one or more ments, such combined with one or more in the art. *A' document member of the same patent: Date of mailing of the international sea	ne application but only underlying the be considered to pument is taken alone laimed invention rentive step when the re other such doou- us to a person skilled family rich report
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Name an	d mailing address of the ISA European Patent Office, P.B. 5818 Patentiaan 2 NL - 2280 HV Rijswijk Tel. (+31-70) 340-2040, Tx. 31 651 epo nl,	Authorized officer SCHEU, M	

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PCT/US 99/07271

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C.(Continua	ation) DOCUMENTS CONSIDERED TO BE RELEVANT	
Category °	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	ARATANI K ET AL: "PROCESS AND DESIGN CONSIDERATIONS FOR SURFACE MICROMACHINED BEAMS FOR A TUNEABLE INTERFEROMETER ARRAY IN SILICON" PROCEEDINGS OF THE WORKSHOP ON MICRO ELECTRO MECHANICAL SYSTEMS (ME, FORT LAUDERDALE, FEB. 7 - 10, 1993, no. WORKSHOP 6, 7 February 1993 (1993-02-07), pages 230-235, XP000366885 INSTITUTE OF ELECTRICAL AND ELECTRONICS ENGINEERS ISBN: 0-7803-0957-X page 232	1-8,10, 11,15
X	GOOSSEN K W ET AL: "SILICON MODULATOR BASED ON MECHANICALLY-ACTIVE ANTI-REFLECTION LAYER WITH 1 MBIT/SEC CAPABILITY FOR FIBER-IN-THE-LOOP APPLICATIONS" IEEE PHOTONICS TECHNOLOGY LETTERS, vol. 6, no. 9, 1 September 1994 (1994-09-01), pages 1119-1121, XP000468079 ISSN: 1041-1135 the whole document	1-7, 9-11,15
X	EP 0 667 548 A (AT & T CORP) 16 August 1995 (1995-08-16) column 3, line 12 - line 35 column 4, line 54 -column 6, line 30; figure 2	1-7, 9-11,15
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International application No. PCT/US 99/07271

Box I Observations where certain claims were found unsearchable (Continuation of item 1 of first sheet)
This International Search Report has not been established in respect of certain claims under Article 17(2)(a) for the following reasons:
Claims Nos.: because they relate to subject matter not required to be searched by this Authority, namely:
Claims Nos.: because they relate to parts of the International Application that do not comply with the prescribed requirements to such an extent that no meaningful International Search can be carried out, specifically:
3. Ctaims Nos.: because they are dependent claims and are not drafted in accordance with the second and third sentences of Rule 6.4(a).
Box II Observations where unity of invention is lacking (Continuation of item 2 of first sheet)
This International Searching Authority found multiple inventions in this international application, as follows:
As all required additional search fees were timely paid by the applicant, this International Search Report covers all searchable claims.
2. As all searchable claims could be searched without effort justifying an additional fee, this Authority did not invite payment of any additional fee.
3. As only some of the required additional search fees were timely paid by the applicant, this International Search Report covers only those claims for which fees were paid, specifically claims Nos.:
4. No required additional search fees were timely paid by the applicant. Consequently, this International Search Report is restricted to the invention first mentioned in the claims; it is covered by claims Nos.: 1-15,23,24
Remark on Protest The additional search fees were accompanied by the applicant's protest. No protest accompanied the payment of additional search fees.

FURTHER INFORMATION CONTINUED FROM PCT/ISA/ 210

1. Claims: 1-15,23,24

An interferometric modulator comprising a cavity defined by two walls wherein the first wall is movable relative to the second wall and within the plane of the first wall

2. Claims: 16-18

Interferometric modulator comprising three walls and control circuitry for driving at least one of three walls

3. Claims: 19-20

an interference modulator comprising spacers mounted to form part of one of the walls

4. Claims: 21,22,25

Interference modulator comprising means to control the response time of the modulator

5. Claim: 26

6. Claims: 27-32

An interferometric modulator, comprising walls and a support and at least one of the walls or the support comprising at least two materials

7. Claims: 33-38,44-48

A method of etching and patterning a microelectromechanical structure

8. Claims: 39-43

a method of making arrays of microelectromechanical structure on a production line

Intermation on patent family members

Interna' Application No
PCT/US 99/07271

Patent document cited in search report	Publication date	Patent family member(s)	Publication date
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